

Erratum to: Strategies to obtain pattern fidelity in nanowire growth from large-area surfaces patterned using nanoimprint lithography

Gaute Otnes, Magnus Heurlin, Mariusz Graczyk, Jesper Wallentin[†], Daniel Jacobsson[‡], Alexander Berg, Ivan Maximov, and Magnus T. Borgström (✉)

Solid State Physics, Lund University, Box 118, S-221 00 Lund, Sweden

[†] Present address: Division of Synchrotron Radiation Research, Lund University, Box 118, S-221 00 Lund, Sweden

[‡] Present address: nCHREM/Centre for Analysis and Synthesis, Lund University, Box 124, S-221 00 Lund, Sweden

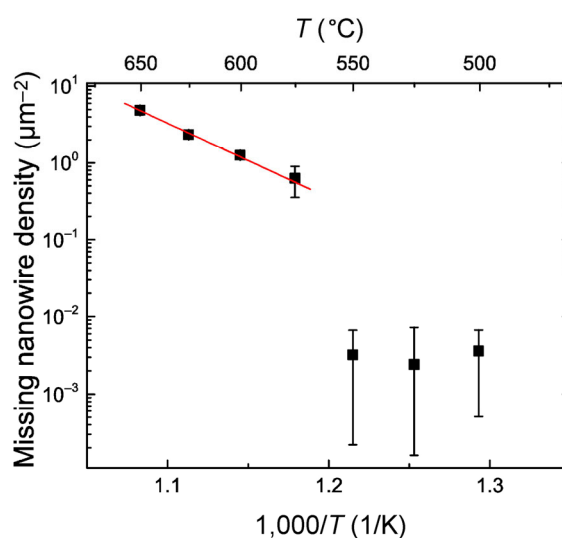
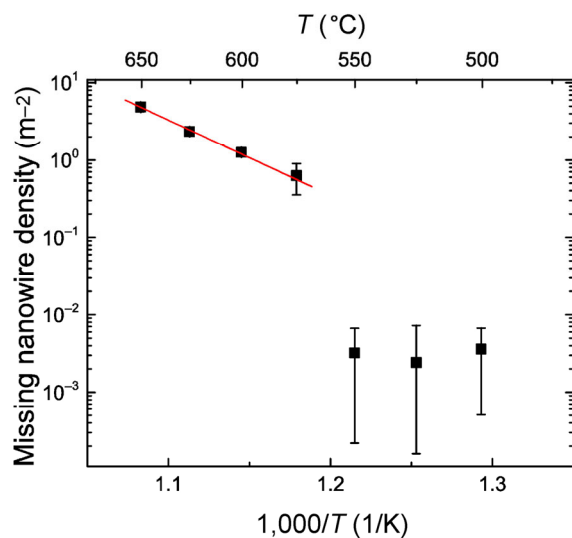
© Tsinghua University Press and Springer-Verlag Berlin Heidelberg 2016

Erratum to

Nano Research 2016, 9(10): 2852–2861
DOI 10.1007/s12274-016-1165-z

The unit of y axis in Fig. 2 in the original version of this article was unfortunately wrongly written on page 2856, instead of m^{-2} .

It should read μm^{-2} .



The online version of the original article can be found at
<http://dx.doi.org/10.1007/s12274-016-1165-z>

Address correspondence to magnus.borgstrom@ftf.lth.se